N 8 5 - 3 2 4 2 1 COMPREHENSIVE SILICON SOLAR-CELL COMPUTER MODELING

RESEARCH TRIANGLE INSTITUTE

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Synopsis of Significant Progress

- Model and analysis of the net charge distribution in quasineutral regions (investigation continuing in collaboration with Professor F A. Lindholm, University of Florida)
- Experimentally determined temperature behavior of Spire Corp. n+pp+ solar cells where n+-emitter is formed t. *j* ion implantation of ⁷⁵As or ³¹P (Acknowledgments: M. B. Spitzer, Spire Corp.; and Ward J. Collis, North Carolina A&T State University, Greensboro, N.C.)
- 3. Initial validation results of computer simulation program using Spire Corp. n+pp+ cells.

Model and analysis of the net charge distribution in quasineutral regions: a model and a corresponding analysis has been developed that describes the net charge distribution which gives rise to built-in electric fields. Conclusions derived from analysis are:

- a. only the redistribution of majority carriers, from their charge neutrality distribution, may affect the establishment of high-intensity built-in electric fields
- b. charge neutrality exits in quasineutral regions only for position-independent and exponential doping concentration profiles
- c. all other doping profiles produce a net charge concentration distribution
- d. new mass action law is developed that applies to quasineutral regions in which charge neutrality is not present.

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Application to n+-region:

Electron concentration distribution:

$$n_n(x) = p_n(x) + N_D(x) - N_A(x) - \Delta N_n(x)$$

Net positive charge concentration:

$$\Delta n_n = \frac{E}{q} \frac{dE_n}{dx}$$

Mass action law:

$$p_{n} = \frac{N_{D} - N_{A} - \Delta n_{n}}{2} \left[\sqrt{1 + \left(\frac{2n_{ie}}{N_{D} - N_{A} - \Delta n_{n}}\right)^{2}} - 1 \right]$$

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for charge neutrality $\Delta n_n = 0$, and $p_n = \frac{n_{ie}^2}{N_D - N_A}$

Substitute p_n into n_n:

$$n_{n} = \frac{N_{D} - N_{A} - \Delta n_{n}}{2} \left[\sqrt{1 + \left(\frac{2n_{ie}}{N_{D} - N_{A} - \Delta n_{n}}\right)^{2}} + 1 \right]$$

for charge neutrality $\Delta n_n = 0$, and $n_n = N_D - N_A + p_n$

Application to n+-region with Gaussian Donor Distribution:

Built-in electric field: $E_n = \zeta \frac{kT}{q} \frac{x}{2Dt}$

$$\zeta = \frac{1}{1 - \frac{N_A - \Delta n_n}{N_D}}$$

Far removed from the depletion region edge: 5 1

$$E_n = \frac{kT}{q} \frac{x}{2Dt}$$

 $\frac{dE_n}{dx} = \frac{kT}{q} \frac{1}{2Dt} = position independent$

 $\Delta n_n - position independent (see Figure 1).$



Figure 1. Representation of the Charge Distribution in the Quasi-Neutral n-Type Emitter Region of a Solar Cell that Establishes a Built-In Electric Field Attributed to a Gaussian Donor Concentration Profile.

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Experimen	ntal Dat	ta Obt	ained	from	n+pp+
Spire	Corp.	Solar	Cells	at 28°	°C Ü

Cell # 4408-	lon (As/P)	Dose (lons/cm ²)	Lը (µm)	QE (@ 350 μm)	VOL (mV)	JSC (mA/cm ²)	FF (%)	EFF (%)
1B	 P	1 x 10 ¹⁴	48	.18	541	20.1	77.1	8.39
4C	P	2 x 10 ¹⁴	46	.31	577	20.7	77.9	9.28
6F	P	4 x 10 ¹⁴	46	.44	603	20.5	79.4	9.81
8C	p	8 × 10 ¹⁴	56	.43	608	21.0	80.1	10.2
10F	P	1 x 10 ¹⁵	78	.42	610	21.7	81.0	10.7
12C	P	2.5 x 10 ¹⁵	94	.37	610	22.4	80.3	11.0
14C	As	1 x 10 ¹⁴	37	.31	559	20.1	71.3	8.03
16B	As	2 x 10 ¹⁴	41	.42	590	20.6	77.0	9.37
17F	As	4×10^{14}	3/	.44	603	20.6	77.5	9.61
20C	As	8 × 10 ¹⁴	38	.47	605	20.6	79.5	9.91
22F	As	1 x 10 ¹⁵	40	.46	603	20.8	80.7	10.1
24C	As	2.5×10^{15}	59	.44	595	22.8	74.1	10.1

Notes: cell area = 4 cm². T = 28°C. Insolation was AMI, 100 mW/cm². No AR coating.

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Figure 2. Experimentally Determined Behavior of Efficiency versus Temperature Obtained from n⁺pp⁺ Spire Corp. Solar Cells Which Do Not Have AR Coatings.



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Figure 3. Experimentally Determined Behavior of Open-Circuit Voltage versus Temperature Obtained from n⁺pp⁺ Spire Corp. Solar Cells Which Do Not Have AR Coatings.

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Calculated Normalized Temperature Coefficients of Efficiency, Open-Circuit Voltage, and Short-Circuit Current Density Obtained from n⁺pp⁺ Spire Corp. Solar Cell Experimental Data Which Do Not Have AR Coatings

	Dos	$a = 1 \times 10^{14}$	cm -2	Dose = $2.5 \times 10^{15} \text{ cm}^{-7}$		
Figure of Merit*	³¹ P(1B)	⁷⁵ As(14C)	Percent Change	³¹ P(12C)	75 A8(24C)	Percent Change
$\frac{1}{\eta_0} \frac{\eta(150) - \eta_0}{\Delta T}$	-4.9 × 10 ⁻³	-4.0 × 10 ⁻³	+ 22 5%	-4.1×10^{-3}	- 3.71 × 10 ⁻³	+ 10.8%
$\frac{1}{(V_{cc})_{o}} \frac{V_{cc}(150) - (V_{cc})_{o}}{\Delta T}$	-4.1 × 10 ⁻³	- 3.7 × 10 ⁻³	+ 10.8%	-3.4×10^{-3}	- 3.4 × 10 ⁻³	0
$\frac{i}{(J_{sc})_{o}} \frac{J_{sc}(150) - (J_{sc})_{o}}{\Delta T}$	0.9 × 10 ⁻³	1.1 × 10 ⁻³	- 18.2%	+ 0 63 × 10 ⁻³	0 7F × 10 ⁻³	- 17.1%
η _ο (Spire Corp)	8.39	8.03	4.5%	11 0	10.1	5.9%
η ₀ (NC A&T)	8.2	7.8	5.1%	10.4	98	6.196

*No AR costing

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Figure 5. Simulation of Electric Field Distribution in n⁺ of Spire Corp. Solar Cell No. 24C With Temperature a Parameter.

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Figure 6. Net Charge Distribution in the n⁺-Region of Spire Corp. Solar Cell No. 24C With Temperature a Parameter. 4

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Figure 8. Lifetime and Transit Time Simulations of Holes in the n+-Region of a n+pp+ Spire Corp. Solar Cell, No. 24C, Under Short-Circuit and 27°C.



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Ln, Base Electron Diffusion Length, µm





